ELECTROSTATIC DISCHARGE CIRCUIT FOR INTEGRATED CIRCUIT WITH MULTIPLE POWER DOMAIN

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Abstract
An ESD protection circuit with multiple domains, which comprises: an ESD protection device, coupled between a first power supplying line and a first ground line; a first internal circuit, having a first terminal coupled to the first power supplying line; a first switch, coupled between a second terminal of the first internal circuit and a second ground line; and a first ESD detection circuit, coupled to the first switch, for detecting an ESD signal, and controls the first switch to be non-conductive when the ESD signal occurs.

14 Claims, 11 Drawing Sheets
FIG. 3a
FIG. 5a
FIG. 6
1. FIELD OF THE INVENTION

The present invention relates to an ESD (Electrostatic Discharge) protection circuit with multiple power domains, and particularly relates to an ESD protection circuit with multiple power domains, which can control an internal circuit to be non-conductive with a power supplying line or a ground line while detecting an ESD signal.

2. DESCRIPTION OF THE PRIOR ART

Normally, an ESD protection mechanism, which is always provided for an internal region of an integration circuit, always locates between an I/O pad and an internal circuit. However, the integration circuit may have a plurality of power domains, and an ESD phenomenon may occur at interfaces between different power domains. Also, in a high speed circuit, a gate oxide of a MOSFET is always thinner, thus a current may easily penetrate the oxide and damage the circuit. Some integration circuits may have ESD protection devices located in signal transmission paths of the power domains. However, such devices may cause the delay of signals and cannot meet the high speed requirement of the circuits.

SUMMARY OF THE INVENTION

One objective of the present invention is to provide an ESD protection mechanism for a circuit of different power domains.

Another objective of the present invention is to provide an ESD protection mechanism not in signal transmission paths.

One embodiment of the present invention provides an ESD protection circuit with multiple domains, which comprises: an ESD protection device, coupled between a first power supplying line and a first ground line; a first internal circuit, having a first terminal coupled to the first power supplying line; a first switch, coupled between a second terminal of the first internal circuit and a second ground line; and a first ESD detection circuit, coupled to the first switch, for detecting an ESD signal, and controls the first switch to be non-conductive when the ESD signal occurs.

Another embodiment of the present invention provides an integration circuit with rush current protection mechanism, which comprises: a first circuit to be protected, having a first terminal coupled to a first power supplying line; a first switch, coupled between a second terminal of the first circuit to be protected and a second ground line; and a first rush current detection circuit, coupled to the first switch, for detecting an ESD signal, and controls the first switch to be non-conductive when the ESD signal occurs.

According to above-mentioned embodiments, ESD protection mechanism for a circuit of different power domains can be provided. Also, the protection device does not locate in signal transmission paths. By this way, the signal delay problem can be avoided.

These and other objectives of the present invention will become obvious to those of ordinary skill in the art after reading the following detailed description of the preferred embodiment that is illustrated in the various figures and drawings.

BRIEF DESCRIPTION OF THE DRAWINGS

FIGS. 1-4 illustrate a circuit diagram of an ESD protection circuit with multiple domains according to an embodiment of the present application.
transmission path (i.e. a signal interface between the power domains first internal circuit 103 and the second internal circuit 115), the signal delay problem in prior art can be avoided.

The ESD protection circuit 120 with multiple domains in FIG. 1b has devices almost the same as which of the ESD protection circuit 100 with multiple domains in FIG. 1a. One of the differences is that the second ESD detection circuit 111 shown in FIG. 1b is omitted. Besides, the ESD protection circuit 120 with multiple domains utilizes the first ESD detection circuit 107 to simultaneously control the first switch 105 and the second switch 109. Accordingly, the first ESD detection circuit 107 controls the first switch 105 and the second switch 109 to be non-conductive when it detects the ESD signal. Therefore, it can be avoided that the ESD current flows to the second internal circuit 115 and flows through the delay device 113 (ex. a resistor) to penetrate the gate oxide layer of the MOSFET of the second internal circuit 115. Other detail technique features are already disclosed in FIG. 1b, thus it is omitted for brevity. In above mentioned embodiments, the first internal circuit 103 includes a PMOS 102 and a NMOS 104. The ESD protection circuit 200 with multiple domains in FIG. 2a has devices almost the same as which of the ESD protection circuit 100 with multiple domains in FIG. 1a. Besides, the first internal circuit 201 in the ESD protection circuit 200 with multiple domains also includes a PMOS 202 and a NMOS 204, the same as the first internal circuit 103 in the ESD protection circuit 100 with multiple domains. One of the differences is that the body of the NMOS 204 in FIG. 2a is directly coupled to the second ground line GND2, but the body of the NMOS 104 in FIG. 1a is directly coupled to a source terminal of the NMOS 104 and the first switch 105. Furthermore, if the structure shown in FIG. 1a is applied, the NMOS 104 can be practiced with a deep N well.

The ESD protection circuit 220 with multiple domains in FIG. 2a has devices almost the same as which of the ESD protection circuit 120 with multiple domains in FIG. 1b. Besides, the first internal circuit 203 in the ESD protection circuit 220 with multiple domains also includes a PMOS 206 and a NMOS 208, the same as the first internal circuit 103 in the ESD protection circuit 120 with multiple domains. One of the differences is that the body of the NMOS 208 in FIG. 2b is directly coupled to the second ground line GND2, but the body of the NMOS 104 in FIG. 1a is directly coupled to a source terminal of the NMOS 104 and the first switch 105.

In the embodiments shown in FIGS. 3a and 3b, the internal circuit in each power domain utilizes a single switch and a single detection circuit for protection. As shown in FIG. 3a, the integration circuit with ESD protection mechanism 300 includes: an ESD protection device 301, an internal circuit 303, a switch 305 and an ESD detection circuit 307. Similarly, the ESD detection circuit 307 is coupled to the switch 305, for detecting an ESD signal (ex. a rush voltage or a rush current), and for controlling the switch 305 to be non-conductive when the ESD signal occurs. In the embodiment shown in FIG. 3a, an internal circuit 309 and the internal circuit 303 belong to different power domains, but the internal circuit 309 also includes a corresponding ESD protection device 311, a switch 313 and an ESD detection circuit 315. Also, the internal circuit 309 also includes the same operation as which of the internal circuit 303.

The ESD protection circuit 320 with multiple domains in FIG. 3b has devices almost the same as which of the ESD protection circuit 300 with multiple domains in FIG. 3a. Besides, the first internal circuit 317 in the ESD protection circuit 320 with multiple domains also includes a PMOS 306 and a NMOS 308, the same as the first internal circuit 303 in the ESD protection circuit 300 with multiple domains. One of the differences is that the body of the NMOS 308 in FIG. 3b is directly coupled to the second ground line GND2, but the body of the NMOS 304 in FIG. 3a is directly coupled to a source terminal of the NMOS 304 and the first switch 305.

In the embodiment shown in FIG. 4, a plurality of the internal circuits can share a protection circuit including two switches and an ESD detection circuit. As shown in FIG. 4, the internal circuits 401 and 403, which can be the internal circuits in the same power region, share the switches 405 and 407 as well as the ESD detection circuit 409. Accordingly, one ESD protection circuit is enough to prevent the ESD current from flowing to the internal circuits 411 and 413.

FIGS. 5a and 5b illustrate exemplary embodiments for the switches of the circuits shown in FIGS. 1a, 1b, 2a, 2b, 3a, 3b and 4. As shown in FIG. 6, the ESD detection circuit 600 includes a first resistance device 601, a second resistance device 603 and an inverter 605. An input terminal of the inverter 605 is coupled to the NMOS 501 shown in FIG. 5a, and an output terminal of the inverter 605 is coupled to the PMOS 503 shown in FIG. 5b. Additionally, the first resistance device 601 and the second resistance device 603 can be implemented by a diode, a capacitor or a resistor.

FIG. 7 illustrates a circuit diagram of an ESD protection circuit 700 with multiple domains utilizes the structures shown in FIGS. 5a, 5b, and 6. As shown in FIG. 7, the ESD protection circuit 700 with multiple domains includes an internal circuit 701, a first switch 703, a second switch 705 and an ESD detection circuit 707. In this embodiment, the first switch 703 is a NMOS, the second switch 705 includes a PMOS 711 and an inverter 713, and the ESD detection circuit 707 includes a resistor 715 and a capacitor 717. In the normal situation, the power Vcc2 can charge the capacitor 717, such that the point A will keep at a high level state, as well as the first switch 703 and the second switch 705 become conductive. It should be noted that the structure shown in FIG. 7 is only for example and does not mean to limit the scope of the present application. Persons skilled in the art can vary the circuit structure to obtain the same results.

According to above-mentioned embodiments, the ESD protection mechanism for circuits of different power domains can be provided. Also, the protection device does not locate in signal transmission paths. By this way, the signal delay problem can be avoided.

Those skilled in the art will readily observe that numerous modifications and alterations of the device and method may be made while retaining the teachings of the invention.

What is claimed is:
1. An ESD protection circuit with multiple domains, wherein the ESD protection circuit comprises:
a first ESD protection device coupled between a first power supplying line and a first ground line;
a first internal circuit, having a first terminal coupled to the first power supplying line;
a first switch, coupled between a second terminal of the first internal circuit and a second ground line, wherein the second ground line is different from the first ground line;
a first ESD detection circuit, coupled between a second power supplying line and the second ground line, coupled to the first switch, for detecting an ESD signal, and controls the first switch to be non-conductive when the ESD signal occurs, wherein the second power supplying line is different from the first power supplying line,
a second internal circuit, coupled between the second power supplying line and the first ground line; and
a second ESD protection device, coupled between the second power supplying line and the second ground line.
2. The ESD protection circuit of claim 1 further comprising:
a second switch, coupled between the first terminal of the first internal circuit and the first power supplying line; and
a second ESD detection circuit, coupled between the first power supplying line and the first ground line, coupled to the second switch, for detecting an ESD signal, and for controlling the second switch to be non-conductive when the ESD signal occurs.
3. The ESD protection circuit of claim 1, wherein the first switch is a NMOS, and a body of the first switch is directly connected to a source terminal of the first switch.
4. The ESD protection circuit of claim 3, wherein the first switch comprises a deep N well distribution layer.
5. The ESD protection circuit of claim 1, wherein the first switch is a NMOS, and a body of the first switch is directly connected to the second ground line.
6. The ESD protection circuit of claim 1, further comprising a second switch that is coupled between the first terminal of the first internal circuit and the first power line, and is coupled to the first ESD detection circuit as well, wherein the first ESD detection circuit controls the second switch to be non-conductive when the ESD signal occurs.
7. The ESD protection circuit of claim 1, further comprising:
a signal transmission path, coupled between the first internal circuit and the second internal circuit.
8. An integration circuit with rush current protection mechanism, comprising:
a first circuit to be protected, having a first terminal coupled to a first power supplying line;
a first switch, coupled between a second terminal of the first circuit to be protected and a second ground line;
a first rush current detection circuit, coupled between a second power supplying line and the second ground line, coupled to the first switch, for detecting an ESD signal, and controls the first switch to be non-conductive when the ESD signal occurs, wherein the second power supplying line is different from the first power supplying line; and
a second circuit to be protected, coupled between the second power supplying line and a first ground line, wherein the second ground line is different from the first ground line.
9. The integration circuit with rush current protection mechanism of claim 8, further comprising:
a second switch, coupled between the first terminal of the first circuit to be protected and the first power supplying line; and
a second rush current detection circuit, coupled between the first power supplying line and the first ground line, coupled to the second switch, for detecting an ESD signal, and for controlling the second switch to be non-conductive when the ESD signal occurs.
10. The integration circuit with rush current protection mechanism of claim 8, wherein the first switch is a NMOS, and a body of the first switch is directly connected to a source terminal of the first switch.
11. The integration circuit with rush current protection mechanism of claim 10, wherein the first switch comprises a deep N well distribution layer.
12. The integration circuit with rush current protection mechanism of claim 8, wherein the first switch is a NMOS, and a body of the first switch is directly connected to the first ground line.
13. The integration circuit with rush current protection mechanism of claim 8, further comprising a second switch that is coupled between the first terminal of the first circuit to be protected and the first power supplying line, and is coupled to the first rush current detection circuit as well, wherein the first rush current detection circuit controls the second switch to be non-conductive when the ESD signal occurs.
14. The integration circuit with rush current protection mechanism of claim 8, comprising:
a signal transmission path, coupled between the first circuit to be protected and the second circuit to be protected.